Notice of Allowability	Application N .	Applicant(s)
	09/737,642	NAVANIC DANUEL C
	Examiner	WANG, DANIEL C. Art Unit
	José R Díaz	2815
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.		
 This communication is responsive to 11/3/03. The allowed claim(s) is/are 11-26. The drawings filed on are accepted by the Examiner. Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). All b) Some* c) None of the: Certified copies of the priority documents have been received. Certified copies of the priority documents have been received in Application No Copies of the certified copies of the priority documents have been received in this national stage application from the International Bureau (PCT Rule 17.2(a)). 		
 5. Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application) since a specific reference was included in the first sentence of the specification or in an Application Data Sheet. 37 CFR 1.78. (a) The translation of the foreign language provisional application has been received. 6. Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121 since a specific reference was included in the first sentence of the specification or in an Application Data Sheet. 37 CFR 1.78. 		
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application. THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		
7. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.		
 8. ☐ CORRECTED DRAWINGS (as "replacement sheets") must be submitted. (a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached 1) ☐ hereto or 2) ☐ to Paper No 		
(b) ⊠ including changes required by the proposed drawing correction filed 11 June 2002, which has been approved by the Examiner.		
(c) including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No.		
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the margin according to 37 CFR 1.121(d).		
9. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.		
Attachment(s)		
1⊠ Notice of References Cited (PTO-892)	5 ☐ Notice of Informal Pate	ent Application (PTO-152)
 Notice of Draftperson's Patent Drawing Review (PTO-948) Information Disclosure Statements (PTO-1449 or PTO/SB/08), Paper No 	6☐ Interview Summary (P	TO-413), Paper No
	7⊠ Examiner's Amendme	
4☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	8⊠ Examiner's Statement 9□ Other	
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EXAMINER'S AMENDMENT

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

The application has been amended as follows:

19. A method of forming a metal-to-metal antifuse over a planarized surface formed from a metal layer and the top surface of a lower insulating layer, comprising:

forming a first cap layer covering the planarized surface;

forming a via in said first cap layer over said metal layer;

forming a first barrier metal layer to form an antifuse electrode in said via, said via being narrower than said [lower Cu] metal layer, said first barrier metal layer in electrical contact with said metal layer;

planarizing said first barrier metal layer to have an upper surface planarized with an upper surface of said cap layer;

forming a layer of antifuse material over said first barrier metal layer and having edges extending over said cap layer;

forming a second barrier metal layer over said antifuse material layer and having edges aligned with said edges of said antifuse material layer;

forming a second cap layer over said first cap layer and surrounding said antifuse material and said second barrier metal layer;

forming an inter-metal dielectric layer over said second cap layer; and

forming a metal contact in a via in said inter-metal dielectric layer and said second cap layer, said metal contact in electrical contact with said second barrier layer.

Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Shroff et al. (US Pat. Nos. 6,515,343 B1 and 6,509,209 B1) discloses a metal-to-metal antifuse having a first cap 117 formed on the first barrier metal layer (116), and a via in the first cap 117, wherein the via is narrower than the metal layer 102.

Reasons for allowance

The following is an examiner's statement of reasons for allowance: the prior art fails to teach, disclose, or suggest, either alone or in combination, a metal-to-metal antifuse comprising a first cap layer covering the planarized surface formed from a metal layer and the top surface of a lower insulating layer; and a first barrier metal layer having an upper surface planarized with an upper surface of a via formed in the first cap layer, wherein the via is narrower than the metal layer.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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Correspondence

Any inquiry concerning this communication or earlier communications from the examiner should be directed to José R Díaz whose telephone number is (703) 308-6078 or (571) 272-1727, after February 9, 2004. The examiner can normally be reached on 9:00-5:00 Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Tom Thomas can be reached on (703) 308-2772. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

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